

Influence of fluorine doping on the microstructure, optical and electrical properties of SnO₂ nanoparticles

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Abstract Tin dioxide (SnO_2) is one of the most promising functional semiconductor materials; it has stimulated considerable research interest for its wide applications such as optoelectronic devices and solar cells technology. Undoped and fluorine doped tin oxide aerogel nanoparticles have been successfully synthesized by sol-gel route and dryed under supercritical conditions of ethanol. The effect of fluorine concentration on SnO₂ nanoparticles properties was systematically investigated by X-ray diffraction, scanning electron microscopy, transmission electron microscopy, Raman spectroscopy, UV-Vis-IR spectroscopy and impedance spectroscopy. Characterization data showed that both pure SnO₂ and FTO aerogels have a polycrystalline tetragonal rutile structure with a highly (110) plane preferred orientation. The grain sizes in the range of 11-25 nm were obtained depending on the elaboration conditions. Raman spectra show the fundamental peaks at 477, 632, and 782 cm⁻¹, corresponding to the E_g , A_{1g} , and B_{2g} vibration modes, respectively, in good agreement with those for the rutile bulk SnO₂. The optical band gap value of tin oxide decreases from 3.88 to 3.44 eV with the increase of fluorine content. Impedance spectroscopy results indicate that the electrical properties are strongly dependent on

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temperature and doping rate. These results show the strong correlation between the structural, morphological, optical and electrical properties of the samples depending on doping content which was well reflected on the quality of the nanoparticles.

1 Introduction

Nanomaterials and their applications have generated great interest in recent years. Side by side there is an urgent need for developing reliable synthesis methods to obtain nanoparticles with well controlled physical properties such as optical, morphologic, catalytic and electrical, which strongly depend on particle size, shape and agglomeration [1, 2].

Tin dioxide has attracted considerable attention due to their potential applications in optoelectronic, gas sensor, catalysis and photovoltaic devices [1]. It is a transparent conductor member due to its unique physical properties such as high electrical conductivity, transparency in the visible part of the spectrum and high chemical stability [3, 4]. The desirable properties of tin oxide (SnO_2) have led many researchers to study pure and doped SnO_2 in the form of nanoparticles [5–8]. Doping with foreign impurities is an important method to enhance the properties of the nanoparticles in desirable and controllable ways. The most favored dopants are antimony which substitutes the tin cations and fluorine via substituting the oxygen atoms [9].

Usually, fluorine (F) is well a known dopant for SnO_2 to obtain good quality material. It exhibits good transparency and low electrical resistivity caused by the oxygen vacancies and the substitution F doping [10]. Compared to the widely used indium tin oxide (ITO) and antimony doped tin oxide (ATO), fluorine doped tin oxide (FTO) is

presented as good material due to its superior physical and chemical properties for a large range of applications like gas sensors [11–13], photocatalysts [14] and solar cells [15, 16]. Indeed, the properties of FTO powder are affected by the preparation process. For that, the synthesis of FTO nanostructures with desired structure and morphology has become a subject of intense research in the last few years.

Thus, it is essential to develop ways for controlling their structure and surface properties. There are several techniques that have been used to prepare FTO nanoparticles and thin films such as chemical vapor deposition [17], hydrothermal [18], solvothermal [19], spray pyrolysis [20] sol–gel [21] and rf-magnetron sputtering [10]. Among these techniques, the sol–gel method attracts most of the attention to the preparation of oxide nanoparticles, with a high quality, because of its several advantages, such as excellent homogeneity, ease of controlling the doping level, ability to coat large areas, complex shapes, and low-cost processing [22].

Until now, much research has been done on the synthesis and characterization of undoped SnO_2 and FTO thin films using the sol–gel technique. However, there are few works, which have been reported on synthesis of FTO nanopowder using this method, except from Gamard et al. [23] who used it on fluorine doped SnO_2 nanocrystals preparation, starting from organic precursors including Sn–F bonds, and followed by thermal treatment in air at 550 °C to obtain nanocrystalline FTO.

Therefore, the synthesis of highly crystallized fluorine doped SnO_2 through an easy method is still a challenge. The aim of this work was to develop a new process to avoid this conflict and prepare a high quality FTO nanopowder, which can be used in the future as a target material for sputtering deposition of thin films in solar cells technology.

In this study, we report a simple protocol using a slightly modified version of the conventional sol–gel method used to synthesize tin oxide aerogels. The effects of fluorine concentration on structural, morphological, optical and electrical properties of the obtained nanopowders were investigated.

2 Experimental details

The tin(II) chloride dehydrated [SnCl₂·2H₂O, purity 98%], ammonium fluorine [NH₄F, purity 99.9%], methanol [CH₄O, purity 99.99%] and ethanol [C₂H₆O, purity 99.99%] used in this work were analytical grade reagents, without any further purification.

Nanocrystalline FTO aerogels were successfully synthesized by sol-gel method. In a typical synthesis process 16 g of SnCl₂·2H₂O was dissolved in 112 ml of methanol. After 30 min under magnetic stirring, at room temperature, adequate quantities of NH₄F, corresponding to [F]/[Sn] atomic ratios of 0.01, 0.02, 0.03, 0.04 and 0.05 were added. The solution was transferred to a Pyrex glass beaker, placed in an autoclave and dried in the supercritical conditions of ethyl alcohol ($T_c = 243 \,^{\circ}$ C; $P_c = 63.6$ bars). Furthermore, the samples were annealed at 500 °C in air for 2 h in order to enhance their cristallinity.

The products were characterized by X-ray diffraction (XRD) using a SIEMENS D 5000 diffractometer with a CuK α radiation (λ =1.5406 Å, 40 kV, 40 mA). Elemental composition of FTO nanoparticles was analyzed using a scanning electron microscope (JEOL, JSM 5410 LV) with an energy dispersive X-ray spectroscopy (EDS) attachment. The microstructures and crystal structures of the nanoparticles were obtained using JEM-200CX transmission electron microscopy (TEM). The formation of FTO phase is further confirmed by Raman spectroscopy measurements at room temperature, using a Raman spectrometer (Renishaw inVia Reflex Spectrometer System) with a 514 nm Argon laser line as an excitation source. The experiments were repeated several times to confirm our result. Optical absorption properties were investigated using a Shimadzu UV3101PC Spectrophotometer in the wavelength range from 200 to 2500 nm. The electrical measurements were performed using a two electrode configuration. The polycrystalline SnO₂ samples were pressed into pellets of about 13 mm diameter and 2 mm thickness at a pressure of 20 MP a using a hydraulic press. In order to ensure ohmic contact, a thin silver film is deposited by thermal evaporation on the both sides of the pellet through a disk shaped mask. Silver wires were attached to both sides of the pellet by silver paint, giving a plate capacitor configuration. For temperature measurements, the sample is mounted in the cryostat. Electrical impedances were carried out at different temperatures using an impedance analyzer agilent 4294 A in the frequency range from 40 Hz to 1 MHz.

3 Results and discussion

Figure 1 shows the XRD patterns of FTO aerogel nanoparticles with different F doping concentrations (0, 1, 2, 3, 4 and 5 at.%). All the observed peaks can be indexed in the tetragonal structure of SnO_2 according to the JCPDS card number 005-0467. The diffractograms reveal that the structure of SnO_2 remains unchanged for low-doping concentration. This suggests that the fluoride ions are fully incorporated into the tin oxide lattice, without changing the tetragonal structure. This can be explained by the fact that the ionic radius of F⁻ (1.33 Å) is close to that of O²⁻ (1.32 Å) [24], so the doping process can take place easily. The lattice constants a and c were calculated from XRD data for the (110) plane, and are given in Table 1.



Fig. 1 X-ray patterns of FTO aerogel nanoparticles for various fluorine doping levels

$$\frac{1}{d_{hkl}^2} = \frac{h^2 + k^2}{a^2} + \frac{l^2}{c^2} \tag{1}$$

where h, k and l are the Miller indices, a and c are the lattice constants, and the inter-plane distance (d_{hkl}) were calculated for all of the FTO nanoparticles using Bragg's diffraction equation:

$$d_{hkl} = \frac{n\lambda}{2\sin\theta} \tag{2}$$

where *n* is a positive integer, λ is the X-ray wavelength and θ is the Bragg's angle. The lattice constants calculated from the XRD patterns are found to be very similar to the SnO₂ ones, i.e. a=b=4.737 Å and c=3.186 Å [25]. The results indicate that FTO has a polycrystalline tetragonal rutile structure with a highly (110) plane preferred orientation, which agrees well with the results of previous published work by Shanshan et al. [19]. However, the comparison of the diffraction patterns of the samples revealed a variation in both intensity and broadness of the peaks. The peaks recorded for the powder obtained with 1 at.% F doped SnO₂ were more intense and narrower than those of the samples prepared with F doping more than 1 at.%. Furthermore, it is worth mentioning that the (110) diffraction

FTO (at.%)	(110), 20	β (°)	$d_{hkl}({ m \AA})$	G (nm)	a (Å)	c (Å)	a/c
0	26.66	0.3490	3.341	23.40	4.736	3.185	1.486
1	26.62	0.3245	3.345	25.16	4.730	3.183	1.486
2	26.60	0.3556	3.348	22.95	4.734	3.184	1.486
3	26.58	0.5118	3.358	15.94	4.737	3.186	1.486
4	26.57	0.6143	3.360	13.28	4.751	3.179	1.494
5	26.56	0.7872	3.365	11.72	4.758	3.175	1.498



Fig. 2 Evolution of FHWM and grain size (G) of the FTO nanoparticles for different doping concentrations

Table 1 Variation of the (110) peak positions, FWHM (β), inter-planar distances (d_{hkl}), grain size (G) and lattice constants of FTO nanoparticles synthesis for different doping

concentration





peak progressively shifted towards lower diffraction angle values compared to the peak position observed in the undoped sample, and broadened as the fluorine content was increased (Table 1; Fig. 1). These results indicate an increase in the lattice disorder due the strain induced by F^- substitution [26].

The mean grain size of nanoparticles was estimated from Scherrer's formula [27, 28]:

$$G = \frac{0.9\lambda}{\beta cos\theta} \tag{3}$$

where λ is the X-ray wavelength, θ is the maximum of the Bragg diffraction peak (in radians) and β is the full width at half maximum (FWHM) of the XRD peak. The average grain size ranged from 11 to 25 nm. Indeed, for the undoped sample the crystallite size was about 23 nm and it increased rapidly to 25 nm, for 1 at.% F doped SnO₂, then

it decreased with the raising of fluorine content as it was shown in Table 1. Figure 2 presents the variation of grain size and the FWHM with F doping concentration. It is clearly observed that, as the nanoparticles become smaller, the FWHM keeps increasing with the increase of F doping content. This indicates that the crystallinity of the powders decreases gradually depending on the dopant incorporation. On the other hand, we found that after the incorporation of F, with the decrease in the particle size, a/c ratio increases from 1.486 to 1.498 suggesting the compressed state of the lattice (Table 1). Thus, it implies that all the doped samples exhibit compressive stresses, due to the substitution of O²⁻ by F⁻ ion. Similar behavior was observed by Thirumoorthi et al. [29]. It is therefore concluded that the fluorine content strongly affects the structure of SnO₂, as observed elsewhere [30].

To further study the morphology of these nanoparticles, TEM measurements combined with high-resolution TEM was employed. Figure 3 shows the TEM images of FTO nanoparticles with different doping levels. It's obvious that the particles are basically spherical in shape and in an agglomerated form by superposition of nanometric size particles. The TEM images also show that the particle size of undoped SnO₂ is smaller than 50 nm. However, further increase of fluorine content, will lead to smaller grain size than that of the undoped sample (Fig. 3b, c). It can be therefore concluded that F doping improves the growing up of nanosized tin oxide. These observations confirm the size of SnO₂ nanoparticles calculated from the Scherrer's equation (Table 1) which indicates that the nanoparticles are well-crystallized in all cases. The HR-TEM images of undoped and fluorine doped SnO₂ are also shown in Fig. 3, confirming the presence of highly crystalline rutile-type SnO₂. The well-resolved lattice fringes (Fig. 3d, e) show that the spacing is about 0.33 nm corresponding to the (110) plane of the rutile crystal structure of the nanocrystalline SnO₂. In order to confirm the chemical composition of FTO nanoparticles, EDS analysis was performed. The results reported in Table 2 confirmed the presence of fluorine in the SnO₂ matrix with no other impurities. This means that FTO nanoparticles were homogeneous and quasi-stoichiometric.

Table 2 Atomic compositions of FTO nanoparticles

at.% F	O (at.%)	Sn (at.%)	F (at.%)
0	69.21	30.79	0
1	67.86	30.66	1.48
2	66.13	31.86	2.01
3	65.28	31.60	3.12
4	65.19	30.61	4.20
5	64.77	29.90	5.33

Raman spectroscopy is a useful tool for the characterization of nanosized materials and is a qualitative probe of the presence of lattice defects in solids. Figure 4 presents the typical room temperature Raman spectra of the assynthesized undoped and F doped SnO₂ (3 at.%). Three fundamental Raman peaks are observed at 477, 632, and 782 cm⁻¹, corresponding to the E_g , A_{1g} , and B_{2g} vibration modes, respectively, in a good agreement with those for the rutile SnO_2 single crystal [31–33]. It is noted that the A1g mode of F doped SnO2 is more broadened than that of the undoped sample, which is induced by the size effect of crystallites. In addition to the fundamental Raman peaks of rutile SnO₂, there are other peaks observed at 297 and 366, 710 cm⁻¹ corresponding to IR-active E_u TO and E_u LO modes, respectively. On the other hand, the Raman mode A_{2g} is observed only at 410 cm⁻¹ [34, 35] in the case of FTO nanoparticles, may be due to the doping effect. These additional Raman peaks are similar to the Raman spectra of SnO₂ nanopowder reported previously [36].

Absorption spectroscopy was used to explore the effect of the synthesis method and the synthesis conditions on the optical properties of SnO_2 nanoparticles. It is well known that theory of optical absorption gives the relationship between the absorption coefficients α and the photon energy $h\nu$ for direct allowed transition as [37]:

$$(\alpha h\nu)^2 = C(h\nu - E_g) \tag{4}$$

where E_g is the apparent optical band gap and *C* is a constant characteristic of the material. The direct band gap is determined using this equation when the straight portion of the $(\alpha h\nu)^2$ against $h\nu$ plot is extrapolated to intersect the energy axis at $\alpha=0$. Figure 5 shows the plots of $(\alpha h\nu)^2$ versus photon energy $h\nu$ for FTO nanoparticles with



Fig. 4 Room-temperature Raman spectra of FTO nanoparticles: undoped $SnO_2(a)$ and 3 at.% F doped $SnO_2(b)$



Fig. 5 Plots of $(\alpha h\nu)^2$ versus photon energy $h\nu$ of FTO nanoparticles

Table 3 Band gap (E_{σ}) and
Urbach energy (E _u) of samples
with different fluorine doping
concentrations

FTO (at.%)	$E_{g}\left(eV ight)$	E _u (eV)
0	3.881	0.634
1	3.872	0.645
2	3.854	0.652
3	3.701	0.755
4	3.672	0.777
5	3.444	0.805

different doping concentrations. The linear part of the plot has been extrapolated towards energy axis. The estimated band gap values are listed in Table 3. The values obtained

Fig. 6 Evolution of the energy band gap (E_g) and the Urbach energy (E_u) depending on the dopant levels for the band gap energies of the FTO vary between 3.88 and 3.44 eV and are in good agreement with other reported values [38, 39]. The band gap energies of the SnO_2 materials show a decrease with the increase of doping concentration (Fig. 6).

The band gap of undoped nanoparticles was found to be equal to 3.8 eV which is higher than that of bulk SnO_2 (3.6 eV). This increase in the band gap of both undoped and doped nanoparticles as compared to bulk can be ascribed to quantum confinement effect and the reduction of structural defects. This confirms the good crystalline quality of the nanopowder obtained by sol gel method.

According to Urbach effect; an increase of doping concentration would induce the formation of band tails in the band gap which is expressed by [40]:

$$\alpha = \alpha_0 \, \exp\!\left(\frac{hv}{E_u}\right) \tag{5}$$

where α_0 is a constant and E_u is the Urbach energy, which refers to the optical transition between occupied states in the valence band tail and the conduction band edge. The E_u values are obtained from the inverse of the slope of $Ln(\alpha)$ versus photon energy. As shown in Fig. 6 and reported in Table 3 an increase of the disorder appears from the introduction of dopants (0–5 at.%) in the SnO₂ lattice. This increase is due to increased acceptor levels of interstitial oxygen atoms.

Based on the previous results obtained, we deduced that 1 at.% content is the most amount of fluorine doping. For that, we have chosen this sample to characterize its electrical property and study the strong correlation between the different properties.



Impedance spectroscopy is a powerful method to characterize the electrical properties of materials. The conductivity of the polycrystalline system is led by various processes such as bulk conduction and grain boundary conduction, and the analysis of complex impedance spectra allows to specify the contribution of each process in the total conductivity [41, 42]. The impedance spectrum usually represented as the imaginary component of the impedance (-Z'')versus the real component Z', which is referred as Nyquist plot, is taken over a wide frequency range (40 Hz-1 MHz) and shown in Fig. 7. These complex impedance measurements were carried out for undoped SnO₂ and FTO 1 at.% at different temperatures. The plots have the shape of semicircles arcs, indicating that the grains are homogenous in size for different doping rates [43]. It can be seen from Fig. 7a, the existence of semicircles which appear only at temperatures up to 420 K, while in the case of FTO 1 at.% sample, the semicircles became clear from 300 K (Fig. 7b). This can be explained by the enhancement of the conductivity with the temperature and doping. A conductivity threshold is required to extract the signal from the noise. On other hand, a reduction of the semicircles diameters size is observed with the increase in temperature; this reduction reflects the decrease in the resistance value and so a semiconducting character of the material [44]. This phenomenon is mainly assigned to the dependence of the charge carrier mobility with temperature, the conductivity increases with temperature increase.

It is well known that the complex impedance analysis permits the correlation between the microstructure of the sample and its electrical properties. Usually, the material is modeled by an electrical equivalent circuit. According to the complex impedance plots shown in Fig. 7, all samples can be modeled by an electrical circuit composed by a grain resistance Rg connected in series with a parallel combination grain boundaries resistance Rgb and capacitance Cgb.

The frequency dependent electrical properties of a material are normally described in terms of its conductivity (σ) which has been calculated from the conductance G by using the relation:

$$\sigma = \frac{e}{G \times S} \tag{6}$$

where e/S represents the geometrical sample ratio.

Figure 8a, b show the variation of the conductivity with frequency of SnO_2 and FTO 1 at.% at different temperatures, respectively. The frequency dependence of the conductivity is characterized by the occurrence of a frequency independent region for each temperature. In the low frequency region, a plateau is observed, where the conductivity is frequency independent. But in the higher frequency region (f > 10 kHz), it increases with increasing frequency; this region is called "a dispersive region". In such region,



Fig. 7 a, b Experimental Nyquist diagrams of SnO_2 and FTO 1% samples measured at different temperature

the frequency dependence can be described by the Jonscher's power law [45]:

$$\sigma \propto A\omega^s \tag{7}$$

where *A* is a pre-exponential factor and *s* is the frequency exponent which depends on temperature.

The deduced *s* values from fits using Eq. (7), in the high frequency region, for different measurement temperatures, are depicted in Fig. 9a, b. The obtained values indicate that 0 < s < 1, characterizing the probable dominance of hopping conduction mechanism [45, 46] and proving that process is thermally activated. Also, the *s*(T) curve is in good agreement with Mott law:

$$s = 1 - \left(6k_{\rm B}T/W_{\rm m}\right) \tag{8}$$



(b)

(a) 0.014

> 0.013 0.012

Fig. 8 a, b Variation of the conductivity of different FTO samples versus frequency



Exponent (s) 0. 0.: 300 350 400 450 500 Temperature (K)

where W_m is the binding energy, which is defined as the energy required to remove an electron completely from one

site to another site and k_B is Boltzmann's constant. For the same temperature, we show that the conductivity of the FTO 1 at.% sample is higher than that of SnO₂ one. This increase in conductivity can be related to the increase of the grain size and the substitution of O^{2-} ions by the F⁻ doping ions.

To sum up, doping affects well on the electrical properties of material that it improves the conductivity and impedance of the sample. This may be explained as follow: when fluorine is incorporated in tin oxide, each F⁻ anion substitutes an O²⁻ anion in the lattice and the substituted O²⁻ anion introduces more free electrons. This results in an increase in free electrons with fluorine doping. Moreover, the F atoms that occupy the proper lattice positions contribute to enhance the disorder (grain boundary) of the structure and grain size which increase the charge carrier mobility.

Fig. 9 a, b Exponent s versus measurement temperature of the synthesized SnO₂ and FTO 1% nanoparticles

4 Conclusion

In the present study, Fluorine doped SnO₂ aerogel nanoparticles were successfully synthesized by using a relatively simple sol-gel method followed by a drying in the supercritical conditions of ethyl alcohol. The effect of Fluorine doping on the structural, morphological, optical and electrical properties of SnO₂ was investigated. XRD studies reveal that the samples exhibit good crystallinity with a tetragonal structure. The grain size of as-synthesized FTO is calculated to be 11-25 nm from XRD and TEM patterns. The optical band gap of FTO nanoparticles depends on F doping and varies from 3.88 to 3.44 eV. Impedance spectroscopy and conductivity results indicate that the electrical properties are strongly dependent on temperature and doping. It was concluded that the crystallinity and optical properties of the SnO₂ nanomaterials depend strongly on Fluorine doping rate. This work has shown also the ability to

SnO₂

grow FTO nanoparticles with lower levels of doping using a cost effective and environmentally friendly method.

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